

Off-Campus Study Quick Facts

ACM & Lawrence University
Partners in higher education since 1958.

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WHY ACM?

Lawrence University is one of a select number of member schools in the Associated Colleges of the Midwest (ACM) consortium. As a result, choosing an ACM program can offer you several advantages:

- An on-campus faculty advisor for every ACM program.
- Course credits which should easily transfer to your college.
- Ease in the use of Financial Aid for your program.
- No application fee to apply to ACM programs.
- A long history of students from your college attending ACM programs.

CAMPUS APPLICATION PROCEDURES

- Participation on an off-campus program requires approval by the Lawrence Subcommittee on Off-Campus Study.
- Students must apply using the Lawrence Off-Campus Study Proposal. The application forms may be obtained online, but must be completed in hard copy and filed at the International House.
- By the Lawrence application deadline, students must turn in completed materials for both the Lawrence proposal and the ACM program application. Lawrence application material is available on the Off-Campus Programs website or by contacting the Off-Campus Programs Coordinator in the International House.

CAMPUS DEADLINES

February 1, 2010 - Application deadline for all off-campus study programs for the 2010-2011 academic year.

FACULTY PROGRAM ADVISORS

Botswana - Lifongo Vetinde
Chicago Arts - Katherine Privatt
Chicago Business, Entrepreneurship, & Society - Marty Finkler
Chicago Urban Studies - Martyn Smith
Costa Rica (fall program) - Patricia Vilches
Costa Rica (spring program) - Jodi Sedlock
Florence/London & Florence - Carol Lawton
India - Dirck Vorenkamp
Japan - Hiroko Yamakido
Newberry Seminar - Paul Cohen
Oak Ridge Science Semester - Nancy Wall
Tanzania - Peter Peregrine

OFF-CAMPUS STUDIES STAFF

Laura Zuege - Off-Campus Programs Coordinator (x. 7354)

STUDENT CAMPUS COORDINATOR

Claire Hammer - hammerc@lawrence.edu
Alumna of ACM Costa Rica program, Fall 2008